ABSTRACT OF THE DISCLOSURE

A sputtering target contains a target material including as constituent elements Ag, In, Te and Sb with the respective atomic percents (atom.%) of α , β , γ and δ thereof being in the relationship of $0.5 \le \alpha < 8$, $5 \le \beta \le$ 23, $17 \le \gamma \le 38$, $32 \le \delta \le 73$, $\alpha \le \beta$, and $\alpha + \beta + \gamma + \delta =$ 100, and a method of producing the above sputtering target is provided. An optical recording medium includes a recording layer containing a phase-change recording material which includes as constituent elements Ag, In, Te and Sb with the respective atomic percents of α , β , γ and δ thereof being in the relationship of 1 \leq α < 6, 7 \leq $\beta \le 20$, $20 \le \gamma \le 35$, $35 \le \delta \le 70$, and $\alpha + \beta + \gamma + \delta =$ 100, and is capable of recording and erasing information by utilizing the phase change of the recording material in the recording layer. A method of forming the above recording layer for the optical recording medium is also provided. In addition, there is provided an optical recording method using the above-mentioned phase-change optical recording medium.